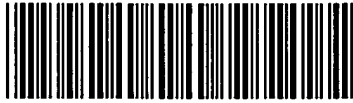


Search Notes

Application/Control No.

10/606,779

Examiner

Paul D. Kim

Applicant(s)/Patent under
Reexamination

IMAMURA, MASAO

Art Unit

3729

SEARCHED

| Class | Subclass | Date | Examiner |
|-------|---|------------|----------|
| 29 | 592.1 595 606 841 847 858 885 | 10/26/2005 | PK |
| 250 | 231.13 | | |
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| 156 | 293 295 311 | | |
| 216 | 22,39,41 | | |
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**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

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